(1) Publication number:

0 200 452

**A2** 

(12)

## **EUROPEAN PATENT APPLICATION**

(21) Application number: 86302982.3

22 Date of filing: 21.04.86

(51) Int. Cl.<sup>4</sup>: **G 02 B 5/20** G 02 B 5/28, G 02 B 1/10 H 01 J 29/86, H 01 J 29/89

(30) Priority: 22.04.85 JP 84662/85

(43) Date of publication of application: 05.11.86 Bulletin 86/45

(84) Designated Contracting States: DE FR GB IT NL

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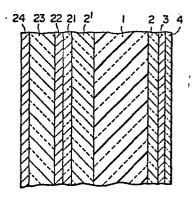
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(54) Light-transmissible plate shielding electromagnetic waves.

(57) A light-transmissible plate having the function of shielding electromagnetic waves comprises a transparent plastic base plate (1), a hard coating layer (2, 2') on the base plate (1), an electroconductive layer (3) on the hard coating layer (2) and a layer (4) having low refractive index on the electroconductive layer (3). The plate (100) can shield electromagnetic waves, and can have high damage resistance even if the plastic constituting the base plate (1) has low surface hardness. Moreover, it is possible to give the plate (100) the function of preventing reflection.

A further anti-reflection film composed of a plurality of layers (21, 22, 23, 24) may be formed on a hard coating layer (2') on the surface opposite to the surface on which the electroconductive layer (3) is provided. The film has excellent adhesion, durability, abrasion resistance, wear resistance, shock resistance, chemical resistance, flexibility, heat resistance, light resistance, weather resistance and static charge resistance, and has excellent properties of shielding electromagnetic waves, eliminating static electricity and preventing reflection.

FIG. 8



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# TITLE OF THE INVENTION

LIGHT-TRANSMISSIBLE PLATE SHIELDING ELECTROMAGNETIC WAVES

### BACKGROUND OF THE INVENTION

# 1. Field of the Invention:

The present invention relates to a
light-transmissible plastic plate which shields

5 electromagnetic waves. More particularly, the present
invention relates to a light-transmissible plate capable of
effectively shielding deleterious electromagnetic waves
which are generated from a display or a Braun tube etc.
Moreover, the present invention relates to a lighttransmissible plate having durability and the function of
reducing reflection.

# 2. Description of the Prior Art:

Displays of office automation equipment, for example word processors or computers etc., or Braun tubes of game machines or television sets generate deleterious electromagnetic waves. There are some problems due to the electromagnetic waves, which are often pointed out, for example, problems with respect to health and noises which influence other equipment. For instance, it often happens that false signals due to noises come into a computer. It

also happens that noises of a stereo are generated when both the stereo and a television set are operating at the same time.

Many improvements have been carried out to

dissolve the problems. One of the improvements is a method of covering the equipment which generate electromagnetic waves, with electroconductive material such as a metal. For example, a cloth capable of shielding electromagnetic waves and an "Eyesaver" (the trade name of a commodity of Chori Kabushiki Kaisha, a Japanese company) are known. The cloth is constructed by adhering carbon onto a fiber with small diameter and then weaving the fiber to form a meshed structure, and the cloth is applied on equipment which generate electromagnetic waves. "Eyesaver" is constructed of glasses and metal wire positioned between the glasses.

However, since the above methods cause a partial intercepting of the ray from a display, it becomes rather difficult for an operator of the equipment to look at the display clearly.

20 A method forming an evaporation coating layer of electroconductive material on a glass base plate is also known. Such a method is disclosed, for example, in Japanese Patent Publication No. SHO 49-18447. However, when the method is applied to a plastic base plate, the base plate is liable to soften or to melt, and is liable to be injured at

the surface. Therefore, the method can not be applied for manufacturing a light-transmissible plastic plate.

Moreover, with respect to anti-reflection film technology, various forming methods and various structures 5 thereof are disclosed. Japanese Patent Publications No. SHO 59-48702, SHO 59-78301 and SHO 59-78304 disclose a method wherein a hard coating film comprising a polyorganosilane or a hardened film comprising an epoxy resin is formed on a plastic base plate and then an anti-reflection film 10 comprising inorganic material is coated on the above hard coating layer. Japanese Patent Publication No. SHO 56-113101 discloses a structure wherein an anti-reflection film comprising a plurality of oxide compound layers is provided on a plastic base plate. The structure has high 15 hardness at the surface and a satisfactory anti-reflection function, but adhesion between the base plate and the film, heat resistance, shock resistance, hot water resistance and weather resistance thereof are not satisfactory. Japanese Patent Publications No. SHO 45-6193, SHO 59-48702, SHO 20 59-78301 and SHO 59-78304 disclose other structures including other anti-reflection films, but the adhesion between the base plate and the anti-reflection film in these structures is also unsatisfactory, and the surfaces of anti-reflection films are liable to be damaged. Moreover, 25 the plates are liable to be damaged by water or alcohol, and

the structures have adhesion problems between the base plate and the film after dipping the plate into hot water and also in severe weather.

Although several conventional technologies have

5 been described, all of these technologies have a problem
in connection with adhesion between a hard coating layer
provided on a base plate and a layer of anti-reflection
film provided on the hard coating layer. Therefore,
the anti-reflection film tends to separate from the hard
10 coating layer over a long period of time.

### SUMMARY OF THE INVENTION

An object of the present invention is to provide a light-transmissible plate which can shield electromagnetic waves wherein an electroconductive layer is coated on a base plate, even if the base plate is constructed of a plastic material.

Another object of the present invention in one of its aspects is to provide a technology wherein hardness at a surface of the light-transmissible plate can be increased.

A further object of the present invention is to provide a technology wherein the light-transmissible plate can also have a function of anti-reflection.

Still another object of the present invention in another aspect thereof is to provide a light-transmissible plate which includes an anti-reflection film having excellent physical properties in various respects.

To accomplish the above objects, a light-transmissible plate according to the present invention comprises:

- electromagnetic waves comprising a transparent plastic base plate, a hard coating layer provided on a surface of the base plate, the hard coating layer having scratch resistance, an electroconductive layer provided on the surface of the hard coating layer, and a layer provided on the surface of the electroconductive layer, said layer having a lower refractive index than the refractive index of the electroconductive layer.
- (2) A light-transmissible plate shielding electro20 magnetic waves comprising a transparent plastic base

plate, a hard coating layer provided on one surface of the base plate, the hard coating layer having scratch resistance, an electroconductive layer provided on the surface of the hard coating layer, a layer provided on the surface of the electroconductive layer, said layer having a lower refractive index than the refractive index of the electroconductive layer, and an anti-reflection film provided on another surface of the base plate, the be anti-reflection film may / composed of a plurality of layers.

### BRIEF DESCRIPTION OF THE DRAWINGS

The present invention will be better understood from the following detailed description taken with accompanying drawings.

FIG. 1 is a sectional view of a
light-transmissible plate having the function of shielding
electromagnetic waves and the function of resisting static
charge according to one embodiment of the present invention.

Light-transmissible plate 100 is constituted as follows.
Hard coating layer 2 is provided on one surface of the
transparent base plate 1, and the hard coating layer 2 has
scratch resistance. Electroconductive layer 3 is provided
on a surface of the hard coating layer 2. Layer 4 is

provided on a surface of the electroconductive layer 3, and

layer 4 has a lower refractive index than the refractive index of the electroconductive layer 3. On another surface of base plate 1, hard coating layer 2' having scratch resistance is provided, and a anti-reflection film 4' is 5 provided on the hard coating layer 2'. Numeral 5 shows a portion of an exposed surface of electroconductive layer 3. Light-transmissible plate 100 is disposed so as to direct a surface having electroconductive layer 3 toward a surface generating picture image, for example, a surface of a cathode-ray tube.

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FIG. 2 is a plan view of the light-transmissible plate 100 in FIG. 1. Exposed surface 5 of electroconductive layer 3 may be formed either along the entire periphery of the light-transmissible plate 100, or along only a part of 15 the periphery. For shielding electromagnetic waves and/or for eliminating static electricity, a metal frame (not shown) is provided around the plate 100 so as to contact with electroconductive layer 3, or an earthing wire 6 is connected to the electroconductive layer 3. The earthing 20 wire 6 is connected desirably to a corner of electroconductive layer 3.

FIG. 3 - 7 show preferred embodiments according to the present invention in relation to connecting an earthing wire. In FIG. 3, hole 9 is provided through the light-transmissible plate 100, and an earthing

wire 15 is connected thereto via metal fitting piece 6a. the connection, it is desirable to use a metal packing 7. Metal fitting piece 6a is fixed by a fixing means, for example, set screw 10a and nut 10b (FIG.3), or a caulking 5 piece 8 (FIG. 4). Then the portion of the connection is covered by a plastic cover 11. FIG. 5 shows an embodiment wherein metal fitting piece 6a is fixed nearly parallel to light-transmissible plate 100 in plastic cover 11. FIG. 6 shows an embodiment wherein helical insert 12 is fitted into 10 hole 9 and earthing wire 15 is fixed by screw 13 via metal fitting piece 6a. In this case, providing a hole 11a on the cover 11 facilitates removing the screw 13, and the structure is convenient for removing light-transmissible plate 100 from equipment or cleaning the plate 100. FIG. 7 15 shows an embodiment wherein earthing wire 15 is connected to the plate 100 via adjuster 14a and 14b.

FIG. 8 is a partial sectional view of a light-transmissible plate having an anti-reflection film constituted by a plurality of layers according to a second embodiment of the present invention. On one surface of transparent plastic base plate 1, hard coating layer 2, electroconductive layer 3 and layer 4 having a lower refractive index than the refractive index of electroconductive layer 3 are provided, and on another surface of base plate 1, hard coating layer 2' having

scratch resistance and anti-reflection film 20 are provided.

Anti-reflection film 20 is constructed of No. 1 layer 21,

No. 2 layer 22, No. 3 layer 23 and No. 4 layer 24.

5 DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

First, the first embodiment of the present
invention is described.

A hard coating layer having scratch resistance is provided on a surface of a transparent plastic base plate.

A plastic constituting the base plate may be any 10 conventional plastic. The transparent base plate means any plastic plate capable of transmitting light. In the case that a light-transmissible plate is used for a display of a word processor etc., it is desirable to apply a base plate 15 set to the transmittance of visible rays of 25 - 70% by its own color or dyeing. The fatigue of the eyes of an operator is reduced by the above restriction. The hard coating layer having scratch resistance means a coating layer having high hardness, for example, a layer including polyorganosiloxane, silica or alumina, or a coating layer 20 constructed of a hardening paint, for example, an acrylic Although / surface of a plastic plate is generally liable to be damaged, characteristics of the surface can be improved by the hard coating layer, and at the same time, adhesion of a layer shielding electromagnetic waves is 25

raised by under-coating the hard coating layer. Most preferably, the hard coating layer consists of a polyorganosiloxane which is produced by heat-condensing after coating methyltrimethoxysilane and vinyltriethoxysilane or after coating hydrolysis compound thereof. Desirable film thickness of the hard coating layer is in the range of about 1 - 10 µm. The hard coating layer including the acrylic is constructed of, for example, a compound crosslinked with an acrylic compound and an ester compound.

The acrylic compound is constructed of, for example, methacrylic acid and the ester compound is constructed of, for example, an ester compound produced from an ester and a polyfunctional glycol, for example, pentaerythritol or glycerin.

Next, an electroconductive layer is provided on a surface of the hard coating layer. Any material having electroconductivity and capable of transmitting light can be used for the electroconductive layer, but preferably the layer is constructed of a mixture with indium oxide (In<sub>2</sub>O<sub>3</sub>) and tin oxide (SnO<sub>2</sub>). The mixture is also called "ITO" hereinafter in this specification. "ITO" has high electroconductivity, can shield electromagnetic waves effectively and can transmit visible rays. A film thickness of the "ITO" layer may be any thickness as long as the layer can satisfy the above functions. A desirable thickness is

in the range of 100 - 3000Å/ If a thickness of more than 300 nm is utilized, cracking is liable to occur. The "ITO" layer can be coated by sputtering. Other methods can be applied for forming the "ITO" layer. For example, the "ITO" layer is formed by evaporation coating using plasma due to high-frequency electric discharge in an atmosphere of oxygen and in a temperature condition of less than 150°C, with the assistance of an ion gun.

Next, a layer having a lower refractive index than 10 the refractive index of the electroconductive layer is provided on the surface of the electroconductive layer. Generally, since an electroconductive layer includes metal, the refractive index of the layer is high. For example, the refractive index of the "ITO" layer is about 2.0. As an amount of reflection becomes larger due to the high 15 refractive index, fatigue of the eyes of the operator also becomes larger. Therefore, it is necessary to provide a layer having a low refractive index on the surface of the electroconductive layer, thereby preventing reflection to the light-transmissible plate. The layer having the low 20 refractive index may be any conventional low refractive layer, but desirably the layer is a layer including inorganic silica. The layer including inorganic silica can be formed by sputtering the silica or by vacuum evaporation 25 coating of the silica. The film thickness of the layer may

be any thickness as long as the layer can appropriately prevent reflection.

In the first embodiment of the present invention, the hard coating layer, the electroconductive layer and the layer having the low refractive index are provided on one surface of the base plate, or on both surfaces of the base plate. In providing them on one surface, it is preferable to provide at least the hard coating layer on another surface to prevent damage of the another surface, and more preferably, the anti-reflection layer is provided on a surface of the hard coating layer.

Next the second embodiment of the present invention is described.

In this embodiment, an anti-reflection film

15 composed of a plurality of layers is provided on a surface of the base plate, the surface being an opposite surface to a surface on which the electroconductive layer is provided.

of the hard coating layer which is provided on one surface of the base plate. The film is constructed of No. 1 layer, No. 2 layer, No. 3 layer and No. 4 layer. The No. 1 layer is provided on the surface of the hard coating layer. The principal ingredient of the No. 1 layer is zirconium oxide. The No. 2 layer is provided on the surface of the surface of the No. 1 layer is zirconium oxide.

silicon dioxide. The No. 1 layer becomes a binder between the hard coating layer and the No. 2 layer, and the strength of both adhesions between the hard coating layer and the No. 1 layer and between the No. 1 layer and the No. 2 layer 5 is increased. The No. 2 layer raises the strength of adhesion against both the No. 1 layer and the No. 3 layer. At the same time, if the No. 1 layer and the No. 2 layer are constructed as an equivalent film, the equivalent film can be a film having a middle refractive index, compared with 10 the No. 3 layer having a high refractive index and the No. 4 layer having a low refractive index. The No. 3 layer is provided on a surface of the No. 2 layer, and the principal ingredient of the No. 3 layer is titanium oxide. The No. 4 layer is provided on a surface of the No. 3 layer, and the 15 principal ingredient of the No. 4 layer is silicon dioxide. The equivalent film (No. 1 layer and No. 2 layer) having the middle refractive index, the No. 3 layer having the high index and the No. 4 layer having the low index, constitute the anti-reflection film as a whole, with the film having 20 the excellent function of preventing reflection.

The above anti-reflection film can be coated by vacuum evaporation or sputtering. Vacuum evaporation is better than sputtering. The assistance of an ion beam may be utilized for forming the film. Titanium oxide can be added into the No. 1 layer including zirconium oxide as long

as the effect of the present invention is not reduced. In the same manner, Ta<sub>2</sub>O<sub>5</sub> can be added to the No. 3 layer including titanium oxide.

The thickness of the anti-reflection film may be any thickness as long as the film can prevent the reflection of visible rays. Preferable optical film thicknesses are as follows when the design wave length  $\lambda$  0 is within 450 - 550 nm.

No. 1 layer; 0.05 - 0.15  $\lambda_0$ ,

No. 2 layer;  $0.05 - 0.15 \lambda_0$ ,

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No. 3 layer; 0.36 - 0.49  $\lambda_0$ , and

No. 4 layer; 0.15 - 0.35  $\lambda_0$ .

Particularly, the thickness of No. 4 layer is desirably 0.25  $\lambda_{\Omega}$ .

15 The anti-reflection film constructed of a plurality of layers is provided on one surface of the plastic base plate, or on both surfaces of the base plate. In providing the film on one surface, it is desirable to provide the hard coating layer on another surface to prevent 20 damage of the other surface. It is also provided that the anti-reflection film may be positioned on one surface of the base plate, and that the hard coating layer and indium oxide-tin oxide layer ("ITO" layer), or the layer including silicon dioxide besides them are provided on another 25 surface. In such a light-transmissible plate, a layer

having the function of preventing reflection is formed on one surface and a layer having the function of shielding electromagnetic waves is formed on another surface. In a structure in which the "ITO" layer is an outermost layer,

5 the film thickness of the "ITO" layer is preferably formed to a small size, for example, 100 - 500Å/ In a structure in which the layer including silicon dioxide is provided on the "ITO" layer, the film thickness of the "ITO" layer is formed to a large size relatively, for example, 500 - 1000Å/. (50-100nm)

In the light-transmissible plate according to the present invention, an earthing means may be connected thereto to eliminate static electricity. In the case that the "ITO" layer is provided, an earthing wire may be connected to the "ITO" layer directly, or continuity via a certain electroconductive piece between the "ITO" layer and the earthing wire may be ensured. As another means, an outer frame constructed of metal may be provided around the plate, and static electricity may be discharged via the frame. Also in this case, the metal frame may preferably come into contact with the "ITO" layer directly, or continuity via a certain electroconductive piece between the metal frame and "ITO" layer may be maintained.

As described in the above, according to the first embodiment of the present invention, providing the hard coating layer on the transparent plastic base plate can

raise the hardness of the light-transmissible plate, thereby providing characteristics of abrasion resistance and wear resistance to the plate, even if the base plate consists of a plastic having low hardness. Providing the

5 electroconductive layer formed on the hard coating layer and the layer having a low refractive index formed on the electroconductive layer, can shield electromagnetic waves, and at the same time can prevent reflection.

According to the second embodiment of the present invention, since the anti-reflection film having excellent static charge resistance is provided on the surface opposite to the surface on which the electroconductive layer is provided, a light-transmissible plate which shields electromagnetic waves can also eliminate static electricity and prevent reflection. Moreover, since the anti-reflection film constructed of a plurality of layers also has excellent strength of adhesion, durability, abrasion resistance, wear resistance, shock resistance, chemical resistance, flexibility, heat resistance, light resistance and weather resistance, excellent optical products can be obtained as a whole.

A representative analysis of components of the electroconductive layer or the anti-reflection film according to the present invention can be carried out by applying Auger electron spectrophotometry. In this method,

an electron beam is irradiated onto a surface of a sample positioned in a high vacuum, and the Auger electron released from the surface is measured by an analyzer with a partition of energy. Conditions of the measurement are as follows.

5 analyzer; "JAMP-105" produced by Nippon Denshi
Kabushiki Kaisha (Japanese company)

degree of vacuum (when measuring an outermost

surface);  $1 \times 10^{-7}$  Pa

degree of vacuum (when measuring in a direction of

depth); 6 x 10<sup>-6</sup> Pa (argon atmosphere)

sampling; to fix a sample on a sample stand
holding an edge of the sample down with
a copper plate

acceleration voltage

15 : 3.0 kV

current flowing through a sample

 $; 1 \times 10^{-8} A$ 

diameter of the electron beam

: 1 um

20 slit used for the measurement

; No. 5

angle of inclination of a sample

: 40 - 70 degree

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etching condition of Ar ion acceleration voltage

; 3.0 kV

current flowing through a sample

 $3 \times 10^{-7} A$ 

etching speed

: 200A/min (20nm/min) (when SiO<sub>2</sub>)

The light-transmissible plate shielding electromagnetic waves according to the present invention is effective, particularly when used as a filter for a television set or a display. As other uses, it is possible to apply the plate as a lens, and it is also possible to form it into various shapes, for example, a film, a block, etc.

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#### **EXAMPLES**

The present invention will be more readily appreciate from the following detailed description of the examples.

## 20 EXAMPLE 1

A polymethacrylate plate on the market is used as a transparent plastic base plate. (The plate is "Acrylite" (trade mark) LN-084, produced by Mitsubishi Rayon Kabushiki Kaisha, colored to gray, thickness; 2 mm.)

A mixture of two compounds (one is obtained by hydrolyzing

vinyltriethoxysilane with glacial acetic acid, another is obtained by hydrolyzing methyltriethoxysilane, with glacial acetic acid) is used as a paint for hard coating, as shown in example 1 of Japanese Patent Publication No. SHO 59-114501. A paint for the present invention is made by adding sodium acetate, which is a hardener, to the mixture and then by adding a surface lubricant including silicon to the mixture. The paint is coated on a surface of the base plate with thickness of  $2\mu$  m, and it is cured by heating. Thus a hard coating layer is formed.

Next, as an electroconductive layer, a mixture of  $\operatorname{In_2O_3}$  and  $\operatorname{SnO_2}$  is coated on the hard coating layer, and the mixture is coated with film thickness of  $700\text{\AA/by}$  sputtering. The condition of the sputtering is at the same condition as shown in example 7 - 9 of Japanese Patent Publication No.

15 SHO 60-32053. That is, the target utilized is indium-tin alloy, a magnetron -sputtering apparatus is used, the atmosphere is a gas mixture of argon and oxygen (oxygen: 30 vol.%), and the vacuum pressure of the atmosphere is 1 x  $10^{-3}$  Torr.

Next, as a layer having low refractive index, a film constructed of silicon dioxide is formed on the electroconductive layer. The film is formed by electron-beam method, using vacuum evaporation coating

apparatus (BMC-800T, produced by Shinku Kikai Kogyo Kabushiki Kaisha). The film thickness is 940Å (94nm).

On the other surface of the base plate, the same hard coating layer as the above is provided. Then, a film of aluminium oxide and a film of silicon dioxide are formed in order on the hard coating layer, thereby giving a function of hardening the surface and preventing reflection to the plate.

has the following functions. Volume of transmission of electromagnetic waves in the frequency of 10 GHz is reduced to about 1/10 volume, compared with only a transparent plastic base plate. When the plate is used as an optical filter for a word processor, it is excellent with respect to preventing reflection, and fatigue of the eyes of the operator is effectively reduced. Hardness of the surface is increased, thereby the plate is tough against abrasion.

the same manner as in example 1. On another surface of the base plate, a hard coating layer is formed in the same manner as in example 1. Then, on the hard coating layer, layers of  $Y_2O_3$  ( $\lambda/4$ ),  $TiO_2$  ( $\lambda/2$ ),  $SIO_2$  ( $\lambda/4$ ) are provided in order.  $\lambda$  is a design wave length.

The light-transmissible plate obtained as the above had the following functions. The volume of transmission of electromagnetic waves in the frequency of 10 GHz is reduced to about 1/22 volume, compared with only a transparent plastic base plate. When the plate is used as an optical filter for a word processor, it is more effective with respect to preventing reflection and preventing abrasion than example 1.

#### EXAMPLE 3

In the example, a polymethacrylate plate having a hard coating layer thereon, being on the market, is used as a base plate. (The plate is "Acrylite" (trade mark)

LN-084, produced by Mitsubishi Rayon Kabushiki Kaisha, colored to gray, thickness; 2 mm.) Other layers, that is,

20 the "ITO" layer and a layer having a low refractive index is formed in the same manner as in example 1. The plate in the example 3 is manufactured to an excellent plate as well as in example 1.

# EXAMPLE 4

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A polymethacrylate plate ("Acrylite" (trade mark)
LN-084, colored to grey, thickness; 2 mm) is used as a base
plate. As a paint for hard coating, a mixture of two

5 compounds (one is obtained by hydrolyzing vinyltriethoxysilane with glacial acetic acid, another is obtained by
hydrolyzing methyltriethoxysilane with glacial acetic acid)
is used, as shown in example 1 of Japanese Patent
Publication No. SHO 59-114501. A paint for the present

10 invention was made by adding sodium acetate, which is a
hardener, to the mixture, and then by adding surface
lubricant including silicon to the mixture.

The paint is coated on both surfaces of the base plate with a thickness of  $2\,\mu\,\text{m}$ , and then it is cured for 3 hours at 90°C. Thus hard coating layers are formed.

Next, the "ITO" layer is coated on the hard coating layer on one surface of the base plate, and then the SiO<sub>2</sub> layer is provided on the "ITO" layer by vacuum evaporation coating. With respect to another hard coating

layer on another surface of the base plate, the surface is set in a vacuum evaporation coating tank. After the tank is heated to 60°C and vacuumed to 1 x 10<sup>-5</sup> Torr, the surface is cleaned with an Argon ion beam generated from the ion beam generating device of the Kaofman type, under the

acceleration voltage condition of 500 V. Then, the

following four layers are formed by electron-beam method, in order, from the surface of the base plate.

- (1) No. 1 layer; the principal ingredient of the layer is zirconium oxide, the optical film thickness is about 42 nm, and the vacuum condition when forming the layer is  $3 \times 10^{-5}$  Torr.
- (2) No. 2 layer; the principal ingredient of the layer is silicon dioxide, the optical film thickness is about 42 nm, and the vacuum condition when forming the layer is 1 x 10<sup>-5</sup> Torr.
  - (3) No. 3 layer; the principal ingredient of the layer is titanium oxide, the optical film thickness is about 216 nm, and the vacuum condition when forming the layer is  $4 \times 10^{-5}$  Torr.
- 15 (4) No. 4 layer; the principal ingredient of the layer is silicon dioxide, the optical film thickness is about 120 nm, and the vacuum condition when forming the layer is  $1 \times 10^{-5}$  Torr.

In the above paragraphs (1) - (4), a design wave length in accordance with the optical film thicknesses is 480 nm.

The plate obtained in the above manner

has a reflection interference color of royal

purple, and has an extremely excellent function of

preventing reflection whereby the surface reflection factor

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at 550 nm is about 0.2%. The plate also has an excellent hardness at the surface. A sheet of polyester fiber, which is formed into a square having a side of 2 cm and which is dropped into water, is positioned on the surface of the plate, a load of 2 Kg is put on the sheet, and then the sheet is moved reciprocally maintaining the above load condition, but there is no abrasion thereon.

An atmospheric exposure test is carried out

by exposing the plate outdoors for one month. The

result is that there is no break away of the anti-reflection

film and no damage of the surface. When the plate is used

as an optical filter for a word processor, it is extremely

excellent with respect to preventing reflection, and fatigue

of eyes of an operator is highly reduced. Durability of the

plate is also excellent.

Moreover, the following measurement was carried out with respect to the property of static charge resistance. An electrostatic voltmeter ("Statiron M", produced by Shishido Seidenki Kabushiki Kaisha, Japanese company) is positioned spacedly 53 mm from the front surface of a CRT. The CRT (NEC-KD551K) is connected to a personal computer (PC-9801E, produced by Nihon Denki Kabushiki Kaisha). When the switch of the personal computer is on, the electrostatic potential measured by "Statiron M" is more than 9 kV. Next, the plate according to the present

invention is positioned between the CRT and "Statiron M", at a position 30 mm from "Statiron M". The plate is grounded. Then, the personal computer was on, but electrostatic potential measured by "Statiron M" is maintained at 0. The effect of static resistance due to the plate was extremely excellent.

### CLAIMS :

1. A light-transmissible plate for shielding electromagnetic waves characterized in that,

a hard coating layer (2) is provided on a surface of a transparent plastic base plate (1), said hard coating below the layer having scratch resistance;

an electroconductive layer (3) is provided on the surface of said hard coating layer (2); and

a layer (4) is provided on the surface of said electroconductive layer (3), said layer (4) having a lower refractive index than the refractive index of said electroconductive layer (3).

- 2. A light-transmissible plate according to claim 1, wherein said electroconductive layer (3) is a layer containing indium oxide and tin oxide.
- 3. A light-transmissible plate according to claim 2, wherein said layer containing indium oxide and tin oxide is formed by sputtering.
- 4. A light-transmissible plate according to claim 2, wherein said layer containing indium oxide and tin oxide

  20 is formed by evaporation coating, said evaporation coating being performed using plasma due to high-frequency electric discharge, in an atmosphere of oxygen and at a temperature of less than 150°C, with the assistance of an ion gun.
- 5. A light-transmissible plate according to any
  25 preceding claim, wherein the film thickness of said electroconductive layer (3) is within the range of 10 to 300nm.

- 6. A light-transmissible plate according to any preceding claim, wherein said hard coating layer (2) is a layer containing organopolysiloxane.
- 7. A light-transmissible plate according to any
  5 one of claims 1 to 5, wherein said hard coating layer (2)
  is formed by coating with a hardening paint.
  - 8. A light-transmissible plate according to any preceding claim, wherein said transparent plastic base plate (1) is a coloured plate.
- 9. A light-transmissible plate according to any preceding claim, wherein said layer (4) having said low refractive index is a layer constructed of inorganic silica.
- 10. A light-transmissible plate according to claim 9,
  15 wherein said layer constructed of inorganic silica is formed by a vacuum evaporation coating.
  - 11. A light-transmissible plate according to any preceding claim, wherein a ground wire (6, 15) is connected to said electroconductive layer (3).
- 20 12. A light-transmissible plate according to any preceding claim, wherein an outer frame is provided around said light-transmissible plate, said outer frame extending along the edge of said light-transmissible plate and coming into contact with said electroconductive layer.
- 25 13. A light-transmissible plate according to any one of claims 1 to 12, wherein a further hard coating layer (2') is provided on the surface of the transparent

plastic base plate (1) opposite to the surface bearing the hard coating layer (2).

- 14. A light-transmissible plate comprising a transparent plastic base plate (1) both sides of which bear layers according to any one of claims 1 to 12.
- one of claims 1 to 13, having an anti-reflection coating (4':21,22,23,24) on the side of the transparent plastic base plate (1) opposite to the surface bearing the hard coating layer (2).
  - 16. A light-transmissible plate according to claim 15, wherein the anti-reflection coating consists of a plurality of layers (21-24).
- 17. A light-transmissible plate according to claim 16

  15 wherein the anti-reflection coating is applied to a hard

  coating layer (2') and consists of the following layers
  - a first layer (21) provided on a surface of said hard coating layer (21), the principal ingredient of said first layer (21) being zirconium oxide;
- a second layer (22) provided on a surface of said first layer (21), the principal ingredient of said second layer (22) being silicon dioxide;

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a third layer (23) provided on a surface of said second layer (22), the principal ingredient of said third layer (23) being titanium oxide; and

a fourth layer (24) provided on a surface of said third layer (23), the principal ingredient of said fourth layer (24) being silicon dioxide.

18. A light-transmissible plate according to claim 16 or claim 17, wherein the optical film thicknesses of said first to fourth layers (21, 22, 23, 24) are the following thicknesses under a condition which a design wave length  $\lambda_0$  is within 450 - 550 nm;

First layer;  $0.05 - 0.15 \lambda_0$ ,

10 Second layer; 0.05 - 0.15  $\lambda_0$ ,

Third layer; 0.36 - 0.49  $\lambda_0$ , and

Fourth layer; 0.15 - 0.35  $\lambda_0$ .

- 19. A modification of the light-transmissible plate according to any one of claims 15 to 18, wherein the 15 first and second layers are combined into a single layer.
  - 20. A light-transmissible plate according to any one of claims 15 to 19, wherein the layers of anti-reflection coating are films formed by evaporation coating.
- 21. A light-transmissible plate according to any one of claims 15 to 19, wherein the layers of anti-reflection coating applied to the hard coating layer (2') are films formed by sputtering.
  - 22. A light-transmissible plate according to any preceding claim, wherein said light-transmissible plate is an optical filter for a cathode-ray tube.

